Persistent optical gating of a topological insulator

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The spin-polarized surface states of topological insulators (TIs) are attractive for applications in spintronics and quantum computing. A central challenge with these materials is to reliably tune the chemical potential of their electrons with respect to the Dirac point and the bulk bands. We demonstrate persistent, bidirectional optical control of the chemical potential of (Bi,Sb)2Te3 thin films grown on SrTiO3. By optically modulating a space-charge layer in the SrTiO3 substrates, we induce a persistent field effect in the TI films comparable to electrostatic gating techniques but without additional materials or processing. This enables us to optically pattern arbitrarily shaped p- and n-type regions in a TI, which we subsequently image with scanning photocurrent microscopy. The ability to optically write and erase mesoscopic electronic structures in a TI may aid in the investigation of the unique properties of the topological insulating phase. The gating effect also generalizes to other thin-film materials, suggesting that these phenomena could provide optical control of chemical potential in a wide range of ultrathin electronic systems.

INTRODUCTION

The ability to tune the chemical potential of a material using electric fields—the field effect—is central to semiconductor electronics and is an important degree of freedom in many experiments in solid-state physics. Topological insulators (TIs) have attracted much attention because of their spin-polarized surface and edge states, whose unique coupling of electrical and magnetic properties shows promise for spintronics applications, and whose origin in symmetry gives them quantum-mechanical properties attractive for fundamental research and quantum computing (1, 2). Robust control over the chemical potential of TI materials is important if these states are to be used in new technologies or as a venue for exotic physics. Unfortunately, chemical potential tuning is challenging in TIs because the fabrication of electrostatic top gates tends to degrade material properties (3, 4) and the addition of chemical dopants or adsorbates can cause unwanted disorder (5). Advances in materials synthesis have produced alloyed TIs such as (Bi,Sb)2Te3, whose composition can be tuned to reduce bulk conductivity and position the chemical potential close to the bulk band gap (6). However, a dynamic method of tuning the chemical potential is often needed to fully deplete bulk carriers and in experiments where it is necessary to tune precisely to or across the Dirac point.

Much research has focused on controlling the chemical potential of TIs through electrostatic gating (7). To this end, SrTiO3 has emerged as a promising dielectric substrate due in part to its extraordinarily high permittivity at low temperature (8). This allows a significant field effect to be produced by applying a voltage to the backside of the sample, obviating the need for a top-gate structure. However, back-gating techniques do not provide spatial control of the chemical potential in TI films, which is attractive given the particular importance of edges and interfaces in TI physics. Alternatives to electrostatic gating include the adsorption of gases on TI surfaces (9–11), electron irradiation (12), vacuum deposition of potassium (13), contact with organic molecules (14), and controlled structural deformation (15). Exposure to synchrotron radiation during photoemission experiments can produce changes in the surface band structure of semiconductors (16, 17). These effects have been observed in TIs (10, 18) and recently used to locally adjust surface band bending (19). Persistent photodoping has also been observed in a Dirac fermion system based on a HgTe/HgCdTe quantum well (20).

RESULTS

We report a bidirectional optical gating effect in thin films of (Bi,Sb)2Te3 grown by molecular beam epitaxy (MBE) on the (111) face of SrTiO3. Exposure to light with energy above the band gap of SrTiO3 raises the chemical potential of the (Bi,Sb)2Te3 layer, whereas illumination with lower-energy light reduces it. We attribute this to persistent, optically induced electrical polarization in the SrTiO3 substrate caused by light passing through the semitransparent (Bi,Sb)2Te3 layer. Figure 1 shows the evolution of the longitudinal resistance of a (Bi,Sb)2Te3/SrTiO3 heterostructure under illumination by ultraviolet (UV) or visible light. A series of timed exposures to UV light (λ = 375 nm, I = 1 mW/m2), interspersed with dark periods, was performed to demonstrate the optical gating effect and its persistence. With each exposure, the longitudinal resistance evolves consistently with a monotonic increase in the chemical potential of the (Bi,Sb)2Te3 layer. The peak in resistance at t = 1200 s corresponds to the charge neutrality point of the material. At t = 1900 s, a series of lengthening exposures to red light (λ = 635 nm, I = 11.8 W/m2) reverses this effect. Both effects allow continuous tuning of the chemical potential with illumination dose, though the reason for the differing kinetics is not yet clear. Low optical powers were chosen to produce slow dynamics for clarity of presentation; however, with brighter illumination, samples can be tuned across this range in ~<1 s and reproducibly cycled thousands of times. After initial transients, the gating effect shows minimal relaxation for 16 hours (see § S1 in the Supplementary Materials).

To better understand the charge carrier dynamics underlying these resistance changes, we performed Hall effect measurements as a function of both electrostatic gating and UV dose. Figure 2A shows the resistivity and Hall coefficient of a (Bi,Sb)2Te3/SrTiO3 heterostructure as a function of the potential applied to the backside of the sample. The sign change of the Hall coefficient indicates the inversion of the majority charge carrier sign. This signifies that the chemical potential has risen...
into the bulk band gap and past the charge neutrality point. The peak in resistivity coincides with the charge carrier inversion, suggesting that the top and bottom surfaces of the film are both effectively gated (21). Figure 2B shows the resistivity and Hall coefficient as a function of UV exposure with the backside of the sample held at 0 V. The sample was first initialized by exposure to red light and then subjected to a series of timed exposures to UV light. The longitudinal and Hall resistances were measured at magnetic fields between ±1 T during the dark periods between exposures. A comparable response is seen for both electrostatic and optical gating. The Hall response was linear below 1 T for both types of gating, allowing interpretation with a simple one-carrier model. A data point was omitted from (C) and (D) because carrier concentration as a function of either optical or electrostatic gating. A zero-field cusp develops as the sample is subjected to positive gate voltage or after consecutive exposures to UV light. This is consistent with the enhancement of WAL as the chemical potential of the TI channel rises above the top of the valence band into the bulk band gap and surface-bulk scattering is reduced. These data demonstrate the suitability of the optical gating effect for the study of coherent carrier effects in TI materials.

SrTiO$_3$ is a host to several optoelectronic effects, which could complicate these data (23, 24). To rule out the influence of substrate conductivity effects, we measured identically prepared bare SrTiO$_3$ substrates at 3 K and at room temperature. Two-terminal resistance measurements exceeded 10 GΩ regardless of the sample’s illumination history to UV or visible light, indicating that parallel conduction through the substrate is unlikely to affect our data.

The spectral dependence of optical gating, as well as control experiments with additional materials, shows that the effect originates in the SrTiO$_3$ substrates and is adaptable to other materials systems. Figure 4A shows the longitudinal resistance of a (Bi$_2$Sb)$_2$Te$_3$/SrTiO$_3$ heterostructure...
before and after timed exposures to different energies of light from a Xe lamp and monochromator. Red and UV light were used before each exposure to initialize the sample to a regime where resistance changes would map monotonically to chemical potential shift (see inset). The sign of the optical gating effect inverts at the band gap energy of SrTiO$_3$, suggesting that the gating effect originates in the SrTiO$_3$ substrate. Measurements of a (Bi,Sb)$_2$Te$_3$ film grown on InP did not show the bidirectional optical response, indicating that the gating effect we report does not originate from the (Bi,Sb)$_2$Te$_3$ layer. In contrast, a persistent, bidirectional optical response was observed in a thin film of ZnO grown on SrTiO$_3$, showing that the optical gating effect is applicable to a non-TI material (see § 53 in the Supplementary Materials). These data strongly suggest that the optical gating effect will be adaptable to a wide variety of ultrathin materials grown or deposited on SrTiO$_3$.

A room temperature optical gating effect is desirable for the study of TI physics and devices robust against thermal disorder. Figure 4B shows the temperature dependence of the optical gating effect. The strength of the effect weakens but does not vanish as temperature increases to 295 K. This is roughly consistent with the temperature dependence of the dielectric constant of SrTiO$_3$ (25). The 295 K trace is monotonic because optical gating is not strong enough at room temperature to tune this sample through its charge neutrality point. However, optimization of SrTiO$_3$ materials properties might amplify the optical gating effect, increasing its relevance for room temperature applications.

Persistent optical effects are amenable to spatial patterning. By selectively exposing different areas of our samples to measured doses of UV or visible light, we can create arbitrary chemical potential landscapes in a TI channel, which persist for hours after illumination. The bidirectional nature of this effect allows these patterns to be dynamically modified and rewritten in situ, which may be useful for rapid characterization of TI electronic structures. These chemical potential landscapes may be detected with scanning photocurrent microscopy. When electron-hole pairs are photoexcited in a region with a strong chemical potential gradient, they will tend to drift apart. This produces a net photocurrent whose longitudinal component can be detected between the two current leads of a Hall bar. By rastering a laser spot over the surface of a sample while continuously monitoring the zero-bias photocurrent, the gradient of the chemical potential landscape can be imaged.

Photocurrent images of two chemical potential landscapes patterned with the optical gating technique are shown in Fig. 5 (B and C). In each image, the field of view was first initialized p-type by exposure to red light. Rectangular n-type regions (dotted lines) were defined by projecting UV light onto the sample surface before imaging. Numerical integration of the images was performed to extract the induced chemical potential shifts along the channel, yielding potential profiles consistent with the creation of local n-type regions (Fig. 5, D and E). With this technique, arbitrary configurations of p- and n-type regions can be patterned with a resolution of <20 µm. Exposure to the imaging beam degrades the pattern by p-gating the material. However, patterns imaged hours after writing show little evidence of degradation. Spatial potential fluctuations have been reported in photocurrent images of similar TI/SrTiO$_3$ heterostructures (26, 27). The dominance of the patterned photocurrent response observed in our images indicates that optical gating produces chemical potential shifts larger than the intrinsic potential fluctuations present at the length scales accessible to photocurrent microscopy.

**DISCUSSION**

We propose a defect-mediated mechanism in SrTiO$_3$ to account for the bidirectional optical gating behavior of our samples. Persistent
photorefractive effects in SrTiO₃ and other perovskites have been attributed to the optical manipulation of charged defect populations (28, 29). This suggests optical modulation of defect charge states as a means to produce large persistent electric fields in these materials. In our experiments, light with energy above the SrTiO₃ bulk band gap penetrates only a short distance past the semitransparent TI layer and into the substrate. Carriers photoexcited from defects near the interface may recombine with states farther into the SrTiO₃, where the illumination is weaker, and they will be less likely to be reexcited. This produces a charge asymmetry in the defect population below the interface, growing until all illuminated defects are depopulated, or the induced electric field balances the diffusive pressure set up by the optical gradient. We propose that this field is responsible for the gating effect on the (Bi,Sb)₂Te₃ layer. Absent illumination, charges will remain bound in their traps and the gating effect will persist. Alternatively, light with energy below the SrTiO₃ bulk band gap reaches defects throughout the substrate volume, allowing isotropic redistribution of charges and the consequent relaxation of the asymmetry. This model qualitatively explains the spectral dependence and persistence of the effect we observe, and is discussed further in § S4 in the Supplementary Materials.

We have demonstrated a persistent, bidirectional optical effect in SrTiO₃, which we use to write and erase arbitrary chemical potential landscapes in a TI channel without additional materials or lithography. Photocurrent images of p-n junctions patterned with this technique establish that intentional tuning can dominate natural potential fluctuations in this material at length scales accessible to photocurrent microscopy. This optical degree of freedom may facilitate the study of proposed TI phenomena such as topological edge states at p-n junctions (30, 31), Klein tunneling (32), spin filtering (33), bound states outside the Dirac cone (34), and Mach-Zehnder interferometry (35). Through a procedure of incremental writing and erasing, closed regions gated to different potentials could be moved adiabatically, which may have relevance for proposed methods of quantum computation (1, 2). The optical gating effect is also adaptable to other materials grown or deposited on SrTiO₃, suggesting that it may be useful in the study of LaAlO₃/SrTiO₃ heterostructures (36), graphene (37), and transition metal dichalcogenides (38, 39). Persistent optical control of chemical potential may be especially useful for the study of materials incompatible with semiconductor processing techniques or in optical, magnetic, and spectroscopic experiments where electrical contacts are not desirable. The persistence and bidirectionality of the optical gating effect also suggest its potential relevance as a platform for optically defined reconfigurable electronics.

### MATERIALS AND METHODS

Samples consist of six quintuple-layers of (Bi,Sb)₂Te₃ grown by MBE on 5 × 5 × 0.5-mm (111)–oriented SrTiO₃ substrates. The substrates were annealed in oxygen for 2 hours at 875 to 925°C to produce an atomically ordered surface and were screened by atomic force microscopy before growth. Reflection high-energy electron diffraction was performed in situ in the MBE chamber to monitor the growth of the TI films. X-ray diffraction and high-angle annular dark-field scanning transmission electron microscopy were performed after growth to characterize the film crystallinity and interface. Materials characterization data are presented in § S5 in the Supplementary Materials. The (Bi,Sb)₂Te₃ film thickness was chosen to avoid hybridization of the top and bottom surface states while remaining thin enough to effectively gate both surfaces (40). A Bi:Sb ratio of about 1:1 was chosen to position the chemical potential of the films close to the bulk band gap (6). Before gating, all samples showed p-type conductivity with a 2D carrier concentration of order 10¹³ cm⁻². A control sample was grown on (111)-oriented InP to rule out optical gating effects intrinsic to the (Bi,Sb)₂Te₃ material. The MBE growth and characterization of TI materials on SrTiO₃ and InP are discussed in detail in a separate article (41). Identically prepared bare SrTiO₃ substrates were measured to control for substrate photoconductivity. These samples were first annealed in oxygen and then heated to 500°C in the MBE chamber to mimic the thermal history of substrates used for (Bi,Sb)₂Te₃ growth. A 50-nm film of ZnO was also sputtered on (111)-oriented SrTiO₃ to demonstrate the generalizability of the optical gating effect beyond TI materials (see § S3 in the Supplementary Materials).

Samples grown on SrTiO₃ were measured either in the Van der Pauw geometry or after mechanically scratching away the growth layer to form a Hall bar. A Hall bar was patterned on the InP sample with standard photolithography techniques. Except for brief exposure to ambient atmosphere during mounting, samples were kept under vacuum or in a dry nitrogen environment to reduce oxidation. Measurements were conducted in a magneto-optical cryostat. An AC resistance bridge was used to measure Van der Pauw geometry samples. Standard lock-in

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Fig. 5. Writing and imaging p-n junctions in a TI. (A) Scanning reflectance image of a (Bi,Sb)₂Te₃ channel. (B and C) Photocurrent images of the same region showing the longitudinal component of chemical potential gradients due to p-n junctions patterned with the optical gating technique. The channel edges are shown as gray lines for reference. In each image, the field of view was first initialized p-type by exposure to red light from a HeNe laser. Rectangular areas (dotted lines) were exposed to UV light gradients due to the same region showing the longitudinal component of chemical potential. The channel edges are shown as gray lines for reference. In each image, the field of view was first initialized p-type by exposure to red light from a HeNe laser. Rectangular areas (dotted lines) were exposed to UV light before imaging, locally gating these regions p-type. UV exposure and photocurrent imaging were repeated, and the images were averaged to reduce noise. (D) and (E) Schematics generated by numerical integration of (B) and (C), depicting the chemical potential as a function of lateral position on the channel. The temperature was 5 K.
SUPPLEMENTARY MATERIALS

Supplementary material for this article is available at http://advances.sciencemag.org/cgi/content/full/1/9/e1500640/DC1

§ S1. Persistence of the optical gating effect for 16 hours.

§ S2. Superposition of electrostatic and optical gating.

§ S3. Optical gating of ≈50-nm sputtered ZnO film on SrTiO3.

§ S4. Mechanism of the optical gating effect.

§ S5. Sample growth and characterization.

Fig. S2. Superposition of electrostatic and optical gating.

Fig. S5. Sample growth and characterization.

Fig. S6. Superposition of electrostatic and optical gating.

Fig. S7. Sample growth and characterization.

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Data and materials availability: All data are presented in the article and Supplementary Materials. Please direct all inquiries to the corresponding author.

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